



# PROGRAM

## 2014 SID INTERNATIONAL SYMPOSIUM

**June 3-6, 2014 (Tuesday – Friday)**  
**San Diego Convention Center**  
**San Diego, California, USA**

### **Session 1: Annual SID Business Meeting**

**Tuesday, June 3 / 8:00 – 8:20 am / Room 6A**

### **Session 2: Opening Remarks / Keynote Addresses**

**Tuesday, June 3 / 8:20 – 10:20 am / Room 6B**

- 2.1: **Keynote 1: Trends in China's Display Industry and BOE's Role**  
*Mr. Dongsheng Wang, Chairman, BOE Technology Group Co., Beijing, China*
- 2.2: **Keynote 2: The Role of Materials in New Display Technology Developments**  
*Dr. Michael Heckmeier, Senior VP, Liquid Crystals Research and Development, Merck, Darmstadt, Germany*
- 2.3: **Keynote 3: Toward an Immersive Image Experience**  
*Dr. Kazumasa Nomoto, Senior GM, Display Device Development Division, R&D Platform, Sony Corp., Kanagawa, Japan*

### **Session 3: Oxide vs. LTPS TFTs I (Oxide vs. LTPS /Active-Matrix Devices)**

**Tuesday, June 3 / 10:50 am – 12:10 pm / Room 6A**

**Chair:** *Arokia Nathan, University of Cambridge*

**Co-Chair:** *Yoshitaka Yamamoto, Semiconductor Energy Laboratory Co., Ltd.*

- 3.1: **Invited Paper: Oxide versus LTPS TFTs for Active-Matrix Displays**  
*Jin Jang, Kyung Hee University, Seoul, South Korea*
- 3.2: **Invited Paper: Application of Rotation Magnet Sputtering Technology to a-IGZO Film Depositions**  
*Tetsuya Goto, Tohoku University, Sendai, Japan*
- 3.3: **Invited Paper: Future Possibility of C-Axis-Aligned Crystalline Oxide Semiconductor: Comparison with Low-Temperature Polysilicon**  
*Shunpei Yamazaki, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan*
- 3.4L: **Late-News Paper: Advanced ELA for Large-Sized AMOLED Displays**  
*Minhwan Choi, Samsung Display Co., Ltd., Kyunggi-do, South Korea*

### **Session 4: Display Manufacturing: LCD Materials (Display Manufacturing)**

**Tuesday, June 3 / 10:50 am – 12:10 pm / Room 6B**

**Chair:** *Chiwoo Kim, Samsung Display Co., Ltd.*

**Co-Chair:** *Dawei Wang, BOE Technology Group Co., Ltd.*

- 4.1: **Distinguished Paper: Cavity-Shape Control of the Roll-to-Roll Fabricated Novel Microstructure Film for Improving the Viewing-Angle Characteristics of LCDs**  
*Yasushi Asaoka, Sharp Corp., Chiba, Japan*
- 4.2: **Vertical Electrode Fabrication Using Conventional LCD Processes**  
*Kang-il Kim, LG Display Co., Ltd., Kyunggi-do, South Korea*
- 4.3: **Novel Photosensitive Organic Insulator for High-Definition FPD Applications**  
*Hideyuki Nakamura, FUJIFILM Corp., Shizuoka, Japan*
- 4.4: **Vacuumless Lamination of Printable LOCA**  
*Christopher Campbell, 3M Co., St. Paul, MN, USA*

### **Session 5: OLED Devices I (OLEDs)**

**Tuesday, June 3 / 10:50 am – 12:10 pm / Room 1**

**Chair:** *Denis Kondakov, DuPont*

**Co-Chair:** *Franky So, University of Florida*

- 5.1: **Invited Paper: Degradation Analysis of OLEDs by Time-Resolved Photoluminescence Measurements**  
*Hideyuki Murata, Japan Advanced Institute of Science and Technology, Ishikawa, Japan*
- 5.2: **Evidence for the Involvement of Water in the Long-Term Degradation of Green Phosphorescent OLEDs**  
*Tetsuo Tsutsui, Chemical Materials Evaluation and Research Base (CEREBA), Tsukuba, Japan*
- 5.3: **Highly Efficient OLEDs Fabricated on Corrugated High-Index Substrates**  
*Franky So, University of Florida, Gainesville, FL, USA*
- 5.4L: **Late-News Paper: ALA Mediated Metronomic Photodynamic Therapy in Mouse Gliomas Model Using OLEDs**  
*Meng-Huan Ho, AU Optronics Corp., Hsinchu, Taiwan, ROC*

### **Session 6: Display Manufacturing: Flexible Substrates (Display Manufacturing / e-Paper and Flexible Displays)**

**Tuesday, June 3 / 10:50 am – 12:10 pm / Room 2**

**Chair:** *Tian Xiao, CBRITE, Inc.*

**Co-Chair:** *Ryoichi Ishihara, Delft University*

- 6.1: **Invited Paper: Handling Technology of Plastic Substrates in Flexible Display Manufacturing**  
*Min-Feng Chiang, AU Optronics Corp., Hsinchu, Taiwan, ROC*
- 6.2: **Invited Paper: A New Automated Manufacturing Line of All-Printed TFT-Array Flexible Film**  
*Toshihide Kamata, Japan Advanced Printed Electronics Technology Research Association (JAPER), Tsukuba, Japan*

- 6.3: **Application of Nanocomposite Materials in the Backplane Technology of Flexible Displays**  
*Kun-Lung Hsieh, AU Optronics Corp., Hsinchu, Taiwan, ROC*
- 6.4: **Ultra-High Gas-Barrier Films Based on a Layered Stack Having a Few Barrier Layers Fabricated by a Wet-Coating Process and Plasma-Assisted Surface Modification**  
*Yuta Suzuki, LINTEC Corp., Saitama, Japan*

### Session 7: Electroluminescent Quantum Dots (*Emissive Displays*)

Tuesday, June 3 / 10:50 am – 12:20 pm / Room 5

Chair: *Seth Coe-Sullivan, QD Vision, Inc.*

Co-Chair: *Qun Yan, Sichuan COC Display Devices Co. Ltd.*

- 7.1: **Invited Paper: Quantum Dot and Other Nano-Technologies as Extremely Thin Displays and Active Surfaces**  
*Vladimir Bulovic, MIT, Cambridge, MA, USA*
- 7.2: **Red Quantum Dots under the Electron Microscope**  
*George Fern, Brunel University, Uxbridge, UK*
- 7.3: **Influence of Layer Thickness on the Performance of Quantum-Dot Light-Emitting Devices**  
*Jing Chen, Southeast University, Nanjing, China*
- 7.4: **Invited Paper: High-Efficiency Quantum-Dot LEDs for Displays**  
*Jin Jang, Kyung Hee University, Seoul, South Korea*
- 7.5L: **Late-News Paper: Cathodoluminescence Quantum Efficiency of Quantum-Dot Thin Films**  
*Heayoung Yoon, National Institute of Standards and Technology, Gaithersburg, MD, USA*

### Session 8: Oxide vs. LTPS TFTs II (*Oxide TFTs vs. LTPS / Active-Matrix Devices*)

Tuesday, June 3 / 2:00 – 3:20 pm / Room 6A

Chair: *James Chang, Apple, Inc.*

Co-Chair: *Hyun Jae Kim, Yonsei University*

- 8.1: **Invited Paper: Value of LTPS: Present and Future**  
*Hiroyuki Ohshima, Japan Display, Inc., Tokyo, Japan*
- 8.2: **Invited Paper: Current Status and Future Promise of Excimer-Laser Annealing for LTPS on Large Glass Substrates**  
*Rainer Paetzel, Coherent LaserSystems GmbH & Co. KG, Gottingen, Germany*
- 8.3: **Invited Paper: Advantages of IGZO Oxide Semiconductors**  
*Shigeyasu Mori, Sharp Corp., Nara, Japan*
- 8.4L: **Late-News Paper: Electrical Properties of a-IGZO Films Depending on Trap States**  
*Ju-Yeon Kim, Hoseo University, Chungnam-do, South Korea*

### Session 9: High-Resolution LCDs (*Liquid-Crystal Technology*)

Tuesday, June 3 / 2:00 – 3:00 pm / Room 6B

Chair: *Cheng Chen, Apple, Inc.*

Co-Chair: *Takahiro Ishinabe, Tohoku University*

- 9.1: **Invited Paper: Fast High-Resolution Ferroelectric LCDs**  
*Vladimir G. Chigrinov, Hong Kong University of Science and Technology, Kowloon, Hong Kong*
- 9.2: **High-Image-Quality Reflective Color LCD Using Novel RGBW Technology**  
*Masashi Mitsui, Japan Display, Inc., Kanagawa, Japan*
- 9.3: **Analysis of Liquid-Crystal Drop Mura in High-Resolution Mobile TFT-LCDs**  
*Hongpeng Lee, BOE Optoelectronics Technology Co., Ltd., Beijing, China*
- 9.4: **Invited Paper: Highly Birefringence Nematic Liquid Crystals and Mixtures**  
*Przemyslaw Kula, Military University of Technology, Warsaw, Poland*

### Session 10: Flexible OLEDs I (*OLEDs*)

Tuesday, June 3 / 2:00 – 3:20 pm / Room 1

Chair: *Tariq Ali, eMagin Corp.*

Co-Chair: *Yasunori Kijima, Sony Corp.*

- 10.1: **Invited Paper: OLED Lighting Commercialization on Flexible Barrier Film Substrates**  
*Takatashi Tsujimura, Konica Minolta, Inc., Tokyo, Japan*
- 10.2: **Strategic Approach to the Reliable Evaluation of the Water Vapor Barrier Properties for Flexible OLED Displays**  
*Akira Suzuki, Chemical Materials Evaluation and Research Base (CEREBA), Tsukuba, Japan*
- 10.3: **Predicting the Lifetime of Flexible Permeation Barrier Layers for OLED Displays**  
*Bhadri Visweswaran, Princeton University, Princeton, NJ, USA*
- 10.4: **A Delamination Method for Flexible OLED Displays**  
*Chia-Hsun Tu, AU Optronics Corp., Hsinchu, Taiwan, ROC*

### Session 11: Flexible Interactive Displays (*Touch and Interactivity / e-Paper and Flexible Displays*)

Tuesday, June 3 / 2:00 – 3:00 pm / Room 2

Chair: *Steven Bathiche, Microsoft Research*

Co-Chair: *Chao-Yuan Chen, Jiangsu Hecheng Display Technology*

- 11.1: **A 4-mm-Radius Curved Display with a Touch Screen**  
*Takayuki Ikeda, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan*
- 11.2: **Invited Paper: Imperceptible Electronic Skin**  
*Tsuyoshi Sekitani, University of Tokyo, Tokyo, Japan*
- 11.3: **A Curvature Sensing Circuit for Flexible Displays**  
*Po-Yang Lin, AU Optronics Corp., Hsinchu, Taiwan, ROC*

## Session 12: Photoluminescent Quantum Dots (*Emissive Displays*)

Tuesday, June 3 / 2:00 – 3:40 pm / Room 5

Chair: Masayuki Nakamoto, Shizuoka University

Co-Chair: Yong-Seog Kim, Hong-ik University

- 12.1: **Invited Paper: Quantum Dots: The Ultimate Down-Conversion Material for LCDs**  
Jonathan Steckel, QD Vision, Inc., Lexington, MA, USA
- 12.2: **Invited Paper: Colloidal Quantum Rods and Wells for Lighting and Lasing Applications**  
Dmitri Talapin, University of Chicago, Chicago, IL, USA
- 12.3: **Core-Shell Quantum Dots Synthesized by Using Tri-n-Octylphosphine-Assisted Method for High-Color-Saturation Displays**  
Kai Wang, South University of Science and Technology of China, Shenzhen, China
- 12.4: **Surface Exciton Properties of MgO in ZnO-MgO Core-Shell Quantum Dots**  
Wen-Jian Kuang, Southeast University, Nanjing, China
- 12.5L: **Late-News Paper: Quantum Dots for High-Color-Gamut LCDs Using an On-Chip LED Solution**  
Julian Osinski, Pacific Light Technologies, Portland, OR, USA

## Session 13: Oxide vs. LTPS TFTs III (*Oxide vs. LTPS / Active-Matrix Devices*)

Tuesday, June 3 / 3:40 – 5:00 pm / Room 6A

Chair: Man Wong, Hong Kong University of Science & Technology

Co-Chair: Takatoshi Tsujimura, Konica Minolta, Inc.

- 13.1: **Invited Paper: Excimer-Laser Annealing: Microstructure Evolution and a Novel Characterization Technique**  
Paul Christian van der Wilt, Coherent Laser Systems GmbH & Co. KG, Goettingen, Germany
- 13.2: **Invited Paper: LTPS vs Oxide Backplanes for AMOLED Displays: System Design Considerations and Compensation Techniques**  
Reza Chaji, IGNS Innovation, Waterloo, Ontario, Canada
- 13.3L: **Late-News Paper: Roll-to-Roll Processed and Top-Gate-Structured a-InGaZnO TFTs with Large Source/Drain Offsets**  
Kyung Min Kim, LG Display Co., Ltd., Kyunggi-do, South Korea
- 13.4: **Flexible Low-Temperature Solution-Processed Oxide-Semiconductor TFT Backplanes for Use in AMOLED Displays**  
Brian Cobb, TNO/Holst Centre, Eindhoven, The Netherlands

## Session 14: Blue-Phase LCDs (*Liquid-Crystal Technology*)

Tuesday, June 3 / 3:40 – 5:00 pm / Room 6B

Chair: Michael Wand, LC Vision, LLC

Co-Chair: Philip Bos, Kent State University

- 14.1: **Low-Temperature and High-Frequency-Operation Limits of a Blue-Phase Liquid Crystal**  
Fenglin Peng, University of Central Florida, Orlando, FL, USA
- 14.2: **Distinguished Student Paper: Low-Voltage High-Transmittance Blue-Phase LCDs**  
Daming Xu, University of Central Florida, Orlando, FL, USA
- 14.3: **Improving Kerr Constant of Polymer-Stabilized Blue-Phase Liquid Crystal with Multiple Dopants**  
Jian-Gang Lu, Shanghai Jiao Tong University, Shanghai, China
- 14.4: **A Hysteresis-Free Polymer-Stabilized Blue-Phase Liquid Crystal**  
Yifan Liu, University of Central Florida, Orlando, FL, USA

## Session 15: Flexible OLEDs II (*OLEDs*)

Tuesday, June 3 / 3:40 – 5:00 pm / Room 1

Chair: Yusin Lin, AU Optronics Corp.

Co-Chair: Chin Hsin (Fred) Chen, Guangdong Aglaia Optoelectronic Materials Co., Ltd.

- 15.1: **Invited Paper: Printed Organic TFT Arrays and Integrated Circuits**  
Shizuo Tokito, Yamagata University, Yamagata, Japan
- 15.2: **Method to Measure the Optical Performance of Flexible OLED Displays**  
Jong-Ho Chong, Samsung Display Co., Ltd., Kyunggi-do, South Korea
- 15.3: **Development of Side-Roll and Top-Roll Panels for an RGBW High-Resolution Flexible Display Using a White OLED with Microcavity Structure**  
Riho Kataishi, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan
- 15.4L: **Late-News Paper: A 7-in. Full-Color Flexible PMOLED Displays on Plastic Substrates**

## Session 16: Touch Sensor Materials (*Touch and Interactivity*)

Tuesday, June 3 / 3:40 – 4:40 pm / Room 2

Chair: John Zhong, Apple, Inc.

Co-Chair: Reiner Mauch, Schott AG

- 16.1: **Sub-Micron Transparent Metal-Mesh Conductor for Touch-Screen Displays**  
Boris Kobrin, Rolith, Inc., Pleasanton, CA, USA
- 16.2: **Reverse-Offset Printed Single-Layered Metal-Mesh Touch-Screen Panel**  
Young-Man Choi, Korea Institute of Machinery and Materials, Daejeon, South Korea
- 16.3: **Printed Touch Sensors Using Carbon NanoBud Material**  
Erkki Soininen, Canatu Oy, Helsinki, Finland

## Session 17: Plasma Displays (*Emissive Displays*)

Tuesday, June 3 / 3:40 – 5:00 pm / Room 5

Chair: Larry Weber, Consultant

Co-Chair: Ryuichi Murai, Panasonic Co., Osaka, Japan

- 17.1: **Distinguished Student Paper: Origin of Short Statistical Delay of an ACPDP with MgO Nano-Powders**  
Seung-Yeol Yang, Hong-ik University, Seoul, South Korea
- 17.2: **Calcium Magnesium Oxide Nano-Crystals for Improving Priming of High-Xe-Content PDPs**

- Qun Yan, Sichuan COC Display Device Co., Ltd., Mianyang, China*  
17.3: **First-Principles Study on the Secondary Electron Emission of MgO (200) and (111) Surfaces**  
*Yan Tu, Southeast University, Nanjing, China*
- 17.4: **Fluid Simulations and Experiments for Ultra-Thin Shadow-Mask PDPs**  
*Lanlan Yang, Southeast University, Nanjing, China*

### **Special Event: Celebration of the 50th Anniversary of Plasma Display Panels**

**Tuesday, June 3 / 5:00 – 6:30 pm / Room 5**

**Chair:** *Larry F. Weber*

- PDP.1 Invention of the Plasma Display Panel**  
*Donald I. Bitzer, NC State University, Raleigh, NC, USA*
- PDP.2 50 Years of Plasma Display Contributions to the Display Industry**  
*Larry F. Weber, New Palz, NY, USA*
- PDP.3 PDP Technology Version 3.0**  
*Roger Johnson, Information Technology, Ltd., La Jolla, CA, USA*
- PDP.4 Opening the Super-Large-Area Display World with Flexible-Film Displays**  
*Tsuta Shinoda, Shinoda Plasma, Kobe, Japan*

### **Plasma Pioneers Reception**

**Tuesday, June 3 / 6:30 – 8:30 pm / West Terrace**

### **Session 18: Wearable Displays I: Imaging Devices (*Wearable Displays*)**

**Wednesday, June 4 / 9:00 – 10:30 am / Room 6A**

**Chair:** *Gary Jones, Nanoquantum Corp.*

**Co-Chair:** *Jean-Pierre Guillou, Apple, Inc.*

- 18.1: **A 0.23-in. High-Resolution OLED Microdisplay for Wearable Displays**  
*Reo Asaki, Sony Corp., Kanagawa, Japan*
- 18.2: **Color-Filter LCOS with Double-Mirror Structure**  
*Yuet-Wing Li, Himax Display, Inc., Tainan, Taiwan, ROC*
- 18.3: **Fully Integrated CMOS Microdisplays for Wearable Sports and HMD Applications**  
*Petrus Venter, University of Pretoria, Pretoria, South Africa*
- 18.4: **Invited Paper: Development of Eyewear Display Systems: A Long Journey**  
*Mark Spitzer, Google, Mountain View, CA, USA*
- 18.5L: **Late-News Paper: Front-Lit LCOS for Wearable Applications**  
*Yuet-Wing Li, Himax Display, Inc., Tainan, Taiwan, ROC*

### **Session 19: Quantum Dots for LCDs (*Liquid-Crystal Technology*)**

**Wednesday, June 4 / 9:00 – 10:00 am / Room 6B**

**Chair:** *Shui Chih Lien, TCL Group*

**Co-Chair:** *Gang Xu, Hewlett-Packard Co.*

- 19.1: **Invited Paper: Color Workshop on Quantum-Dot-Enhanced Displays**  
*James Hillis, 3M Co., St. Paul, MN, USA*
- 19.2: **Invited Paper: Novel Wide-Color-Gamut LED Backlight for 4K x 2K LCD Embedded with Quantum-Dot Technology**  
*Hirohisa Ishino, Sony Corp., Tokyo, Japan*
- 19.3: **Distinguished Student Paper: Quantum-Dot-Enhanced LCD Color and Optical Efficiency**  
*Zhenyue Luo, University of Central Florida, Orlando, FL, USA*

### **Session 20: Flexible AMOLEDs I (*Active-Matrix Devices / e-Paper and Flexible Displays*)**

**Wednesday, June 4 / 9:00 – 10:20 am / Room 1**

**Chair:** *Kalluri Sarma, Honeywell, Inc.*

**Co-Chair:** *Hsing-Hung Hsieh, Polyera Taiwan Corp.*

- 20.1: **Flexible AMOLED Display and Gate Driver with Self-Aligned IGZO TFTs on Plastic Foil**  
*Soeren Steudel, IMEC, Leuven, Belgium*
- 20.2L: **Late-News Paper: A 4-in. QVGA Flexible AMOLED Driven by Solution-Processed Metal-Oxide TFTs**  
*Liang Lin, AU Optronics Corp., Hsinchu, Taiwan, ROC*
- 20.3L: **Late-News Paper: Flexible AMOLED Display Driven by Organic TFTs on a Plastic Substrate**  
*Charlotte Harrison, Plastic Logic, Cambridge, UK*
- 20.4L: **Late-News Paper: A Flexible AMOLED Display on a PEN Substrate Driven by Oxide TFTs**  
*Lei Wang, South China University of Technology, Guangzhou, China*

### **Session 21: Display Manufacturing: Oxide TFTs (*Display Manufacturing*)**

**Wednesday, June 4 / 9:00 – 10:00 am / Room 2**

**Chair:** *Fang Chen Luo, AU Optronics Corp.*

**Co-Chair:** *Toshiaki Arai, Sony Corp.*

- 21.1: **A 513-ppi FFS-Mode TFT-LCD Using CAAC Oxide Semiconductor Fabricated by A Five-mask Process**  
*Akio Yamashita, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan*
- 21.2: **Invited Paper: Manufacture of MOTFT Backpanel for 440-ppi True-Full-Color AMOLED Displays**  
*Gang Yu, CBRITE, Inc., Goleta, CA, USA*
- 21.3: **A 13.5-in. Quad-FHD Flexible CAAC-OS AMOLED Display with Long-Life OLED Device Structure**  
*Shogo Uesaka, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan*



## Session 22: Low-Power and High-Speed Interface (*Display Electronics*)

Wednesday, June 4 / 9:00 – 10:40 am / Room 5

Chair: Dick McCartney, Samsung Display Co., Ltd.

Co-Chair: Taesung Kim, Intel, Inc.

- 22.1: **Invited Paper:** Challenges and Requirements on Power-Saving Techniques on Mobile Platforms  
*Taesung Kim, Intel, Inc., Santa Clara, CA, USA*
- 22.2: **WITHDRAW**
- 22.3: **Invited Paper:** Intra-Panel Interface Technology for High-Resolution Tablet PC Applications  
*Jae-Youl Lee, Samsung Electronics Co., Ltd., Kyunggi-do, South Korea*
- 22.4: **Invited Paper:** A 1.8-Gbps Intra-Panel Interface with Power Reduction and EMI Suppression Schemes for Tablet PC Applications  
*Kil-Hoon Lee, Samsung Electronics Co., Ltd., Kyunggi-do, South Korea*
- 22.5: **A 7-in. Digital Micro-Shutter Display Driven by IGZO TFT**  
*Taketoshi Nakano, Mie, Japan*

## Session 23: Wearable Displays II: Optics Design (*Wearable Displays*)

Wednesday, June 4 / 10:40 am – 12:00 pm / Room 6A

Chair: David Eccles, Rockwell Collins

Co-Chair: Yi-Pai Huang, National Chiao Tung University

- 23.1: **Optical Design of a Compact See-Through Head-Mounted Display with a Light-Guide Plate**  
*Jui-Wen Pan, National Chiao Tung University, Tainan, Taiwan, ROC*
- 23.2: **Binocular Holographic Waveguide Visor Display**  
*William Bleha, Holoeye Systems, Inc., San Diego, CA, USA*
- 23.3: **Quality of Augmented Information for Different Distances on See-Through Near-to-Eye Displays**  
*Toni Järvenpää, Nokia Research Center, Tampere, Finland*
- 23.4: **Augmented Edge Enhancement for Vision Impairment Using Google Glass**  
*Alex Hwang, Schepens Eye Research Institute, Harvard Medical School, Boston, MA, USA*

## Session 24: FFS/IPS (*Liquid-Crystal Technology*)

Wednesday, June 4 / 10:40 am – 12:00 pm / Room 6B

Chair: Hyun Chul Choi, LG Display Co., Ltd.

Co-Chair: Ki Chul Shin, Samsung Display Co., Ltd

- 24.1: **A Method for Analyzing the Eye Strain in Fringe-Field-Switching LCDs under Low-Frequency Driving**  
*Kung-Ching Chu, AU Optronics Corp., Hsinchu, Taiwan, ROC*
- 24.2: **Investigation of Flexoelectric Effect in VA IPS Mode by Low-Frequency Driving**  
*Cheng-Wei Lai, AU Optronics Corp., Hsinchu, Taiwan, ROC*
- 24.3: **Viewing-Angle Property of Single-Domain AH-IPS Liquid-Crystal Mode Optimized with Polymer-Stabilized Polystyrene Alignment Layer**  
*Hak-Rin Kim, Kyungpook National University, Daegu, South Korea*
- 24.4L: **Late-News Paper: High-Performance Advanced Super Dimension Switch (ADS) Mode LCD with Negative Dielectric Anisotropy LC Optimization**  
*Falu Yang, BOE Optoelectronics Technology Co., Ltd., Sichuan, China*

## Session 25: Flexible AMOLEDs II (*e-Paper and Flexible Displays/Active-Matrix Devices*)

Wednesday, June 4 / 10:40 am – 12:00 pm / Room 1

Chair: Doug Loy, Intellectual Adventures

Co-Chair: Ki-Yong Lee, Samsung Display Co., Ltd.

- 25.1: **Tri-Fold Flexible AMOLED with High Barrier Passivation Layers**  
*Yasuhiro Jimbo, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan*
- 25.2: **Repeatedly Bendable Book-Type AMOLED Display**  
*Ryu Komatsu, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan*
- 25.3: **A 9.55-in. Flexible Top-Emission AMOLED with a-IGZO TFTs**  
*Shiming Shi, BOE Technology Group Co., Ltd., Beijing, China*
- 25.4: **Invited Paper: Development of Commercial Flexible AMOLEDs**  
*Soonkwang Hong, LG Display Co., Ltd., Kyunggi-do, South Korea*

## Session 26: Applications (*Applications*)

Wednesday, June 4 / 10:40 am – 12:00 pm / Room 2

Chair: Jean-Noel Perbet, THALES Avionics

Co-Chair: Adi Abileah, Consultant

- 26.1: **Distinguished Paper: Single-Layer Fabry-Pérot Interferometric Display for Both Color and Intensity Modulations**  
*Chao Ping Chen, Shanghai Jiao Tong University, Shanghai, China*
- 26.2: **Super-Durable Cover Lens Film**  
*Richard Pokorny, 3M Co., St. Paul, MN, USA*
- 26.3: **Edge Adaptive Method of Image Resampling and Enhancement**  
*Vladimir Lachine, Qualcomm Canada, Inc., Toronto, Ontario, Canada*
- 26.4: **Display Color Error in the Medical Digital Image Workflow**  
*Paul Boynton, National Institute of Standards and Technology, Gaithersburg, MD, USA*

## Session 27: Computational Visual Fidelity (*Applied Vision/Human Factors*)

Wednesday, June 4 / 10:40 am – 12:00 pm / Room 5

Chair: James Larimer, ImageMetrics LLC

Co-Chair: Jeffrey Mulligan, NASA Ames Research Center

- 27.1: TBA

- 27.2: **Distinguished Paper:** Modeling Visible Differences: The Computational Observer Model  
Joyce Farrell, Stanford University, Stanford, CA, USA
- 27.3: **Computational Approaches to Aberration Compensation for Vision-Correcting Displays**  
Fu-Chung Huang, University of California at Berkeley, Berkeley, CA, USA
- 27.4L: **Late-News Paper:** VESA Display Stream Compression: An Overview  
Frederick Walls, Broadcom Corp., Grafton, WI, USA

### Session 28: Wearable Displays III: Direct View (Wearable Displays)

Wednesday, June 4 / 3:30 – 5:10 pm / Room 6A

Chair: Ruiqing Ma, Universal Display Corp.

Co-Chair: Susan Jones, Nulumina Corp.

- 28.1: **OLEDs on Textile Substrates with Planarization and Encapsulation Using Multilayers for Wearable Displays**  
Kyung Cheol Choi, KAIST, Daejeon, South Korea
- 28.2: **Genuinely Wearable Display with a Flexible Battery, a Flexible Display Panel, and a Flexible Printed Circuit**  
Ryota Tajima, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan
- 28.3: **Flexible Substrate with Low Reflection, Low Haze, Self-Cleaning, and High Hardness by Nano-Structured Hard Coating and Surface Treatment**  
Jiun-Haw Lee, National Taiwan University, Taipei, Taiwan, ROC
- 28.4: **Wearable Display for Dynamic Spatial and Temporal Fashion Trends**  
Wallen Mphepo, University of Sunderland, Sunderland, UK
- 28.5: **Invited:** Wearable-Display Expectations: Enabling Mobile-Display Experiences of the Future  
Brian Gally, Qualcomm MEMS Technologies, Inc., San Jose, CA, USA

### Session 29: Film and Alignment (Liquid-Crystal Technology)

Wednesday, June 4 / 3:30 – 4:50 pm / Room 6B

Chair: Philip Chen, National Chiao Tung University

Co-Chair: Yukito Saitoh, FUJIFILM Corp.

- 29.1: **A New Achromatic Quarter-Wave Film Using Liquid-Crystal Materials for Anti-Reflection of OLEDs**  
Yuta Takahashi, FUJIFILM Corp., Kanagawa, Japan
- 29.2: **Distinguished Paper:** Wide-Viewing LCDs Using Novel Microstructure Film  
Emi Yamamoto, Sharp Corp., Chiba, Japan
- 29.3: **Performance of Novel LC Photo-Aligning Cinnamoyl Side-Chain Polymers**  
Hiroshi Hasebe, DIC Corp., Saitama, Japan
- 29.4: **Polymer-Stabilized Electrically Suppressed Helix Ferroelectric Liquid Crystal**  
Abhishek Srivastava, Hong Kong University of Science and Technology, Kowloon, Hong Kong

### Session 30: Display Manufacturing: OLEDs (Display Manufacturing)

Wednesday, June 4 / 3:30 – 4:50 pm / Room 1

Chair: Greg Gibson, FAS Holdings Group

Co-Chair: Ion Bitu, Qualcomm MEMS Displays, Inc.

- 30.1: **Invited Paper:** A 65-in. Ink-Jet-Printed Organic Light-Emitting Display Panel with High Degree of Pixel Uniformity  
PengYu Chen, AU Optronics Corp., Hsinchu, Taiwan, ROC
- 30.2: **Invited Paper:** Advancements in Ink-Jet Printing for OLED Mass Production  
Conor Madigan, Kateeva, Inc., Menlo Park, CA, USA
- 30.3: **Invited Paper:** AMOLED Manufacturing: Challenges and Solutions from a Material Makers Perspective.  
Sven Murano, Novaled AG, Dresden, Germany
- 30.4: **Distinguished Student Paper:** Development of a Novel Pattern-Coating Technology: Air-Bubble Coating for the Manufacture of OLED Devices  
Yu-Wen Hsieh, National Taiwan University, Taipei, Taiwan, ROC

### Session 31: Laser Speckle (Display Measurement / Projection)

Wednesday, June 4 / 3:30 – 4:50 pm / Room 2

Chair: Chuck Yin, Square, Inc.

Co-Chair: Alan Sobel, Flatscreen Technologies Corp

- 31.1: **Speckle Reduction Due to the Use of Electro-Optical Cell with Helix-Free FLC**  
Igor Kompanets, P. N. Lebedev Physical Institute of RAS, Moscow, Russian Federation
- 31.2: **Speckle Contrast Reduction with a Small-Vibrated Reflective Intermediate Screen for a MEMS Scanning Laser Projector**  
Shih-Yu Tu, National Taiwan University, Taipei, Taiwan, ROC
- 31.3: **Classification of Subjective Speckle for the Evaluation of a Laser Display**  
Makio Kurashige, Dai Nippon Printing Co., Ltd., Chiba, Japan
- 31.4: **Standardization of Speckle Measurement for Large-Screen Laser-Illuminated Video Projection Systems**  
Terry Schmidt, Christie Digital Systems, Wellesley, Ontario, Canada

### Session 32: Flexible TFTs (e-Paper and Flexible Displays)

Wednesday, June 4 / 3:30 – 4:50 pm / Room 5

Chair: Shawn O'Rourke, dpiX, LLC

Co-Chair: Ryoichi Ishihara, Delft University of Technology

- 32.1: **Invited Paper:** Novel Approaches for Fabricating High-Performance Low-Temperature Solution-Processed Metal-Oxide Transistors  
Hsing-Hung Hsieh, Polyera Taiwan Corp., Hsinchu, Taiwan, ROC
- 32.2: **Invited Paper:** Integration of Flexible AMOLED Displays Using Oxide Semiconductor TFT Backplanes  
Gerwin Gelinck, TNO/Holst Centre, Eindhoven, The Netherlands

- 32.3: **Invited Paper:** Demonstration of High-Mobility Unisolated Corbino OTFTs with Improved Switching Ratio for Application to Flexible Displays.  
*Michael Cowin, SmartKem, Ltd., St. Asaph, UK*
- 32.4: **Invited Paper:** Solution-Processed Single-Grain Si TFTs on a Plastic Substrate  
*Ryoichi Ishihara, Delft University of Technology, Delft, The Netherlands*

### Session 33: Active-Matrix TFTs (Active-Matrix Devices)

Thursday, June 5 / 9:00 – 10:20 am / Room 6A

Chair: Jerzy Kanicki, University of Michigan

Co-Chair: Chien Hung Chen, AU Optronics Corp.

- 33.1: **Channel-Etched C-Axis-Aligned Crystalline Oxide Semiconductor FETs Using Cu Wiring**  
*Kengo Akimoto, Advanced Film Device, Inc., Tochigi, Japan*
- 33.2: **A New Plasma Process and Structure for Oxide Semiconductor LCDs**  
*Joon-Young Yang, LG Display Co., Ltd., Kyunggi-do, South Korea*
- 33.3: **High Mobility and Highly Stable Aluminum-Doped Indium Zinc Tin Oxide TFTs**  
*Sung Haeng Cho, ETRI, Daejeon, South Korea*
- 33.4: **Distinguished Paper: Oxide-Semiconductor TFTs Using Oxygen Barriers and a Wet-Chemical Back-Channel Etch Step**  
*Marcus Herrmann, University of Stuttgart, Stuttgart, Germany*

### Session 34: LC Beyond Displays I (Liquid-Crystal Technology)

Thursday, June 5 / 9:00 – 10:20 am / Room 6B

Chair: Terry Scheffer, Motif, Inc.

Co-Chair: Jian-Gang Lu, Shanghai Jiao Tong University

- 34.1: **Invited Paper: Slowing Light in Liquid Crystals**  
*Umberto Bortolozzo, INLN, Université de Nice Sophia-Antipolis., Valbonne, France*
- 34.2: **Invited Paper: Active Plasmonic Tunable Metamaterials and Ultra-Fast Non-Linear Optics with Liquid Crystals**  
*Iam Choonk, Pennsylvania State University, University Park, PA, USA*
- 34.3: **Invited Paper: On the Correlation between Electron Polarizability of Molecular Core and Its Input into Optical Anisotropy**  
*Piotr Harmata, Military University of Technology, Warsaw, Poland*
- 34.4: **Invited Paper: THz Devices Based High-Birefringence Liquid Crystals**  
*Yan-qing Lu, Nanjing University, Nanjing, China*

### Session 35: OLED Materials (OLEDs)

Thursday, June 5, / 9:00 - 10:20 am / Room 1

Chair: Chihaya Adachi, Kyushu University

Co-Chair: Chishio Hosokawa, Idemitsu Kosan Co., Ltd.

- 35.1: **Invited Paper: High-Performance OLED materials**  
*Holger Heil, Merck KGaA, Darmstadt, Germany*
- 35.2: **Invited Paper: Improving Efficiency without Compromising Lifetime in Blue Fluorescent OLEDs by ETL Design**  
*Ansgar Werner, Novald AG, Dresden, Germany*
- 35.3: **Invited Paper: The Soluble Hole-Injection Materials and the Inks Applicable to OLED Devices**  
*Kazuhiro Monzen, Nissan Chemical Industries, Ltd., Funabashi, Japan*
- 35.4: **Enhancement of Emission Efficiency in a White OLED Device by Highly Efficient Narrow Spectrum Red-Emission Material**  
*Tomoya Yamaguchi, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan*

### Session 36: Light-Field and Multi-View Displays (3D/Display Systems)

Thursday, June 5 / 9:00 - 10:20 am / Room 2

Chair: Nikhil Balram, Ricoh Innovations, Inc.

Co-Chair: Brian Schowengerdt, University of Washington

- 36.1: **Wide-Field-of-View Compressive Light-Field Display Using a Multilayered Architecture and Viewer Tracking**  
*Gordon Wetzstein, MIT, Cambridge, MA, USA*
- 36.2: **Distinguished Paper: Dual-Layer Three-Dimensional Display with Enhanced Resolution**  
*Na-Young Jo, Inha University, Incheon, South Korea*
- 36.3: **Surround-Type Light-Field Display Provide Immersive Experience**  
*Li Feng, Zhejiang University, Hangzhou, China*
- 36.4: **Design and Calibration of 100-Mpixel Multi-Projection 3D Display with an Enhanced Image Quality**  
*Jin-Ho Lee, Samsung Advancer Institute of Technology, Kyunggi-do, South Korea*

### Session 37: Novel Measurement Standards and Methods (Display Measurement)

Thursday, June 5 / 9:00 - 10:20 am / Room 5

Chair: Chuck Yin, Apple, Inc.

Co-Chair: Stephen Atwood, Azonix Corp.

- 37.1: **OLED Displays under Ambient Illumination: An Implementation of IEC 62341-6-2**  
*Michael Becker, Display-Messtechnik & Systeme, Karlsruhe, Germany*
- 37.2: **Simplified Ambient Performance Assessment for Mobile Displays Using Easy Measurements**  
*William Cummings, Qualcomm MEMS Displays, Inc., San Jose, CA, USA*
- 37.3: **Viewing-Direction Measurements with Hemispherical Diffuse Illumination on e-Paper Displays**  
*Dirk Hertel, E Ink Corp., Billerica, MA, USA*
- 37.4: **Improved Display Color Measurements with the WP214 Imaging Spectral Colorimeter**  
*Chad Greene, Westboro Photonics, Ottawa, Ontario, Canada*

**Session 38: Capacitive Touch (*Touch and Interactivity*)**

**Thursday, June 5 / 10:40 - 11:50 am / Room 6A**

**Chair:** *Jeff Han, Microsoft*

**Co-Chair:** *Joohyung Lee, Samsung Display Co., Ltd.*

- 38.1: **A Fast Readout Circuit for Capacitive Touch-Screen Panels Using A Dual-Mode Sensing Algorithm**  
*Hyeon-June Kim, KAIST, Daejeon, South Korea*
- 38.2: **High-Performance Mutual-Capacitive Touch Screen Using Double-Layered Metal-Mesh Electrodes with Separated Floating Electrodes**  
*Isao Nojiri, Mitsubishi Electric Corp., Kumamoto, Japan*
- 38.3: **One Glass Solution with a Single Layer of Sensors for Projected-Capacitive Touch Panels**  
*Shi-Yu Liu, Shanghai Jiao Tong University, Shanghai, China*

**Session 39: LC Beyond Displays II (*Liquid-Crystal Technology*)**

**Thursday, June 5 / 10:40 am - 12:00 pm / Room 6B**

**Chair:** *Shin Tson Wu, University of Central Florida*

**Co-Chair:** *Terry Scheffer, Motif, Inc.*

- 39.1: **Invited Paper: Emerging Areas for Liquid-Crystal Technologies Beyond Displays**  
*Sin-Doo Lee, Seoul National University, Seoul, South Korea*
- 39.2: **Invited Paper: Stimuli-Responsive Cholesteric-Liquid-Crystal Composites for Optics and Photonics**  
*Timothy White, AFRL, Wright-Patterson AFB, Dayton, OH, USA*
- 39.3: **Invited Paper: Recent Advances on Liquid-Crystal-on-Silicon Spatial Light Modulators**  
*Haruyoshi Toyoda, Hamamatsu Photonics K.K., Hamamatsu, Japan*
- 39.4: **Invited Paper: Liquid Crystal for Ophthalmic Lenses and Biosensing Applications**  
*Yi-Hsin Lin, National Chiao Tung University, Hsinchu, Taiwan, ROC*

**Session 40: OLED Devices II (*OLEDs*)**

**Thursday, June 5 / 10:40 am - 12:00 pm / Room 1**

**Chair:** *Yasunori Kijima, Sony Corp.*

**Co-Chair:** *Jang Hyuk Kwon, Kyung Hee University*

- 40.1: **Novel Two-Mask AMOLED Display Architecture**  
*Michael Hack, Universal Display Corp., Ewing, NJ, USA*
- 40.2: **Building Up Electrical Modeling of a White Fluorescent Top-Emitting OLED: Material Parameter Extraction and Impact of Poole Frenkel and ECDM Mobility Models**  
*Karim Bouzid, CEA-LETI, Grenoble, France*
- 40.3: **One FMM Solution for Achieving AMOLED with 413-ppi Real Pixel Density**  
*Meng-Ting Lee, AU Optronics Corp., Hsinchu, Taiwan, ROC*
- 40.4: **Design Tool for Light-Scattering Enhancement in OLEDs**  
*Stéphane Altazin, Fluxim AG, Winterthur, Switzerland*

**Session 41: Autostereoscopic Systems and Measurement (*3D / Display Systems / Display Measurement*)**

**Thursday, June 5 / 10:40 am - 12:00 pm / Room 2**

**Chair:** *Jae Hyeung Park, Inha University*

**Co-Chair:** *Bill Cummings, Qualcomm MEMS Displays*

- 41.1: **High-Resolution Glassless 3D with Head-Tracking System**  
*Takeo Koito, Japan Display, Inc., Kanagawa, Japan*
- 41.2: **Invited Paper: An UHD Active-Barrier 3D module**  
*Yanbing Wu, BOE Technology Group Co., Ltd., Beijing, China*
- 41.3: **Image Quality Factors for Designs of an Autostereoscopic Display**  
*Yun-Ting Cheng, National Taiwan University, Taipei, Taiwan, ROC*
- 41.4: **Characterization of Multi-View Autostereoscopic Displays Using a Fourier Optics Viewing-Angle Instrument and Video-Luminance Meter**  
*Pierre Boher, ELDIM, Herouville, France*

**Session 42: Human Vision and Measurements for Lighting Systems (*Lighting / Display Measurement / Applied Vision*)**

**Thursday, June 5 / 10:40 am - 12:20 pm / Room 5**

**Chair:** *Ingrid Heynderickx, Eindhoven University of Technology*

**Co-Chair:** *Tom Fiske, Qualcomm MEMS Displays*

- 42.1: **Invited Paper: Optimization and Evaluation of Automotive Displays under Bright Ambient Light Using Novel Image-Enhancement Algorithms**  
*Karlheinz Blankenbach, Pforzheim University, Pforzheim, Germany*
- 42.2: **Invited Paper: Analysis of Background Illuminance Levels During Television Viewing**  
*Kyle Sills, California Lighting Technology Center, Davis, CA, USA*
- 42.3: **Invited Paper: Progress in the Soft Metrology of Appearance: The Contribution of Digital Image Representations**  
*Frédéric Leloup, KU Leuven, KATHO Sint-Lieven, Gent, Belgium*
- 42.4: **Sparkle Measurement Revisited: A Closer Look at the Details**  
*Michael Becker, Display-Messtechnik & Systeme, Karlsruhe, Germany*
- 42.5: **Cross Media Color Reproduction of Real Lighting Environment Using CIECAM02**  
*Ronnier Luo, University of Leeds, Leeds, UK*



**Session 43: Novel Interactivity (Touch and Interactivity)**

**Thursday, June 5 / 1:30 - 2:30 pm / Room 6A**

**Chair:** Bob Senior, Canatu Oy

**Co-Chair:** Deuksu Lee, LG Display Co., Ltd.

- 43.1: **Invited Paper:** Touch-Technology Diversity in Commercial Applications  
Joel Kent, Elo Touch Solutions, Milpitas, CA, USA
- 43.2: **Optical Multi-Touch on a Circular Device**  
Richard Berglind, Neonode, Stockholm, Sweden
- 43.3: **Electrostatic Tactile Display Using a Beat Phenomenon of Voltage Waveforms**  
Hiroshi Haga, NLT Technologies, Ltd., Kawasaki, Japan

**Session 44: Ultra-High-Resolution Displays (Active-Matrix Devices)**

**Thursday, June 5 / 1:30 - 2:50 pm / Room 6B**

**Chair:** Tohru Nishibe, Japan Display, Inc.

**Co-Chair:** Norbert Fruehauf, University of Stuttgart

- 44.1: **Distinguished Paper:** A 13.3-in. 8K x 4K 664-ppi OLED Display Using CAAC-OS FETs  
Susumu Kawashima, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan
- 44.2: **512-ppi Mobile Displays with High Aperture Ratio, Slim Border, and Wide Color Gamut**  
Ming-Hsien Lee, AU Optronics Corp., Hsinchu, Taiwan, ROC
- 44.3: **A 513-ppi LCD Using a C-Axis-Aligned Crystalline Oxide Semiconductor with a Narrow Bezel and an Aperture Ratio Greater than 50%**  
Kouhei Toyotaka, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan
- 44.4L: **Late-News Paper:** Large-Area-Display Backplane Using Embedded Single-Crystal-Silicon Particles  
Douglas Dykaar, DifTek Lasers, Inc., Waterloo, Ontario, Canada

**Session 45: OLED Devices III (OLEDs)**

**Thursday, June 5 / 1:30 - 2:30 pm / Room 1**

**Chair:** Michael Weaver, Universal Display Corp.

**Co-Chair:** Yusin Lin, AU Optronics Corp.

- 45.1: **An Improved Method for Lifetime Prediction Based on the Decoupling of the Joule Self-Heating Effect from Coulombic Degradation in Accelerated Aging Tests of OLEDs**  
Tetsuo Tsutsui, Chemical Materials Evaluation and Research Base (CEREBA), Tsukuba, Japan
- 45.2: **Extraction-Efficiency Enhancement of an AMOLED Display with Acceptable Blur by Attaching Trapezoid Array Film**  
Jiun-Haw Lee, National Taiwan University, Taipei, Taiwan, ROC
- 45.3: **Distinguished Student Paper:** High-Efficiency Tandem Top-Emitting OLEDs  
Jang Hyuk Kwon, Kyung Hee University, Seoul, South Korea

**Session 46: Holographic Display Systems (3D / Display Systems / Applications)**

**Thursday, June 5 / 1:30 - 3:00 pm / Room 2**

**Chair:** Ian Underwood, University of Edinburgh

**Co-Chair:** K. Käländär, Global Optical Solutions

- 46.1: **Colorful Holographic Display Using Variable Spatial Sampling**  
Chenliang Chang, Southeast University, Nanjing, China
- 46.2: **Plasmonic Hologram Based on Bilayer Metallic Nanowire Gratings**  
Zhi-cheng Ye, Shanghai Jiao Tong University, Shanghai, China
- 46.3: **Improvement of Holographic Video Display Using a Super-Fast Refresh and Non-Pixelated Liquid-Crystal Film**  
Hongyue Gao, Shanghai University, Shanghai, China
- 46.4: **Influence of Space-Variant Effect on Axial Error in Digital Holography**  
Chao Ping Chen, Shanghai Jiao Tong University, Shanghai, China
- 46.5L: **Late-News Paper:** Waveguide Display System with Variable Output Intensity  
Nannan Zhang, Beijing Institute of Technology, Beijing, China

**Session 47: OLED Lighting I (Lighting/OLEDs)**

**Thursday, June 5 / 1:30 - 2:50 pm / Room 5**

**Chair:** Jang Hyuk Kwon, Kyung Hee University

**Co-Chair:** Denis Kondakov, DuPont

- 47.1: **Invited Paper:** Color Tunable Phosphorescent White-OLED Lighting Panel  
Michael Weaver, Universal Display Corp., Ewing, NJ, USA
- 47.2: **Invited Paper:** Efficient Tandem Hybrid White OLEDs for Solid-State Lighting Applications  
Yuan-Sheng Tyan, First O-Lite, Inc., Nanjing, China
- 47.3: **Invited Paper:** Performance Improvement of Blue Phosphorescent OLEDs by Designing an Intermolecular and Interlayer Combination  
Kunimasa Hiyama, Konica-Minolta, Inc., Tokyo, Japan
- 47.4: **Distinguished Paper:** Realization of Outstandingly High-Efficacy White OLED by Controlling Evanescent Mode and Wide Angular Incident Light  
Kazuyuki Yamae, Panasonic Eco Solutions Company, Osaka, Japan

**Session 48: Touch Display Manufacturing (Touch and Interactivity / Display Manufacturing)**

**Thursday, June 5 / 3:10 - 4:30 pm / Room 6A**

**Chair:** Willem Den Boer, Guardian Industries

**Co-Chair:** Bradley Bowden, Corning Incorporated

- 48.1: **Invited Paper:** Design and Manufacture of a Slim Notebook-Embedded Touch Panel  
Ching Cheng, AU Optronics Corp., Hsinchu, Taiwan, ROC

- 48.2: **Cover-Glass Strength Design for Industrial Use PCAP LCD Module**  
*Hiroshi Teramoto, Mitsubishi Electric Corp., Kumamoto, Japan*
- 48.3: **Novel Fracture Resistant Glass for a Mobile-Display Cover**  
*Shusaku Akiba, Asahi Glass Co., Ltd., Kanagawa,, Japan*
- 48.4: **The Mirror Constant of Glass Substrates by 4PB Testing**  
*Mao-Hsing Lin, Innolux Corp., Tainan City, Taiwan, ROC*

#### **Session 49: Active-Matrix Design (Active-Matrix Devices)**

**Thursday, June 5 / 3:10 – 4:50 pm / Room 6B**

**Chair:** *Roger Stewart, Sourland Mountain Associates*

**Co-Chair:** *Kazuyoshi Omata, Konica Minolta*

- 49.1: **Flexible Flat-Panel-Display Designs with Gate Driver Circuits Integrated within the Pixel Area**  
*Hidefumi Yoshida, Sharp Corp., Nara, Japan*
- 49.2: **Corbino TFTs for Large-Area AMOLED Displays**  
*Mallory Mativenga, Kyunghee University, Seoul, South Korea*
- 49.3: **High-Resolution Active-Matrix Imager Using Poly-Si Phototransistors in a Magnifying Viewer**  
*Mutsumi Kimura, Ryukoku University, Otsu, Japan*
- 49.4L: **Late-News Paper: Novel Pixel Structure for Quadrupling of Pixel Voltage**  
*Dahye Sim, LG Display Co., Ltd., Kyunggi-do, South Korea*
- 49.5L: **Late-News Paper: An Organic TFT Backplane for Foldable Displays Fabricated by Scalable and Low-Cost Processes**  
*Mao Katsuhara, Sony Corp., Kanagawa,, Japan*

#### **Session 50: Advanced OLED Driving (Display Electronics)**

**Thursday, June 5 / 3:10 - 4:30 pm / Room 1**

**Chair:** *Ya Hsiang Tai, National Chiao Tung University*

**Co-Chair:** *Seung Woo Lee, Kyung Hee University*

- 50.1: **Invited Paper: Technological Progress of Pixel Compensation for OLED TVs**  
*Hong-Jae Shin, LG Display Co., Ltd., Kyunggi-do, South Korea*
- 50.2: **Real-Time TFT Compensation through Power-Line Current Sensing for High-Resolution AMOLED Displays**  
*Jun-Suk Bang, KAIST, Daejeon, South Korea*
- 50.3: **A Novel Power-Saving Technology for OLED TVs with External TFT Compensation**  
*Tae-Gung Kim, LG Display Co., Ltd., Kyunggi-do, South Korea*
- 50.4: **Perception-Optimized Signal Scaling for OLED Power Saving**  
*Min Dai, Qualcomm, Inc., San Diego, CA, USA*

#### **Session 51: Liquid-Crystal Lens and Doping for 3D (3D / Liquid-Crystal Technology)**

**Thursday, June 5 / 3:10 - 4:30 pm / Room 2**

**Chair:** *Kei-Hsiung Yang, National Chiao Tung University*

**Co-Chair:** *Jenn Jia Su, AU Optronics Corp.*

- 51.1: **Real-Time Holographic Display Using Quantum-Dot Doped Liquid Crystal**  
*Yikai Su, Shanghai Jiao Tong University, Shanghai, China*
- 51.2: **Large-Angle Image Steering Using a Liquid-Crystal Device**  
*HsienHui Cheng, Liquid Crystal Institute, Kent State University, Kent, OH, USA*
- 51.3: **Design for Reducing Autostereoscopic Display Crosstalk Using a Liquid-Crystal Gradient-Index Lens**  
*Masahiro Kasano, Panasonic Corp., Osaka, Japan*
- 51.4: **Dielectric-Force-Induced Liquid-Crystal Lenticular Microlenses**  
*Hong Ren, Chonbuk National University, Jeonju, South Korea*

#### **Session 52: OLED Lighting II (Lighting/OLEDs)**

**Thursday, June 5 / 3:10 - 4:30 pm / Room 5**

**Chair:** *Chin Hsin (Fred) Chen, Guangdong Aglaia Optoelectronic Materials Co., Ltd.*

**Co-Chair:** *Lee-Mi Do, ETRI*

- 52.1: **Invited Paper: Highly Efficient Transparent OLEs with An Internal Random Nano-Structured Scattering Layer**  
*Jeong-Ik Lee, ETRI, Daejeon, South Korea*
- 52.2: **Invited Paper: Development and Manufacture of OLED Lighting Panels for Health-Care Application**  
*John Hamer, OLEDDWorks LLC, Rochester, NY, USA*
- 52.3: **Understanding Extrinsic Degradation in Phosphorescent OLEDs**  
*Hitoshi Yamamoto, Universal Display Corp., Ewing, NJ, USA*
- 52.4: **Highly Efficient Single-Unit White OLED Device with Emission from Both Singlet and Triplet Excitons**  
*Takahiro Ishisone, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan*

#### **Session 53: OLED TV I (OLED TV/OLEDs)**

**Friday, June 6 / 9:00 - 10:20 am / Room 6A**

**Chair:** *Sven Murano, Novaled AG*

**Co-Chair:** *Michael Weaver, Universal Display Corp.*

- 53.1: **Development of Oxide-TFT OLED-TV Technologies**  
*Yu-Hsin Lin, AU Optronics Corp., Hsinchu, Taiwan, ROC*
- 53.2: **Invited Paper: Advanced Technologies for Large-Sized OLED TV**  
*Chang-Wook Han, LG Display Co., Ltd., Kyunggi-do, South Korea*
- 53.3: **Structural Advantage of WRGB OLED Displays for Edge Enhancement**  
*Taeseong Han, LG Display Co., Ltd., Kyunggi-do, South Korea*
- 53.4: **Color Optimization for OLED Displays**  
*Sang Choi, Samsung Display Co., Ltd., Kyunggi-do, South Korea*

### Session 54: e-Paper I (*e-Paper and Flexible Displays*)

Friday, June 6 / 9:00 - 10:20 am / Room 6B

Chair: Chao-Yuan Chen, Jiangsu Hecheng Display Technology

Co-Chair: Rashmi Rao, Apple, Inc.

- 54.1: **Invited Paper:** Structural Colors for Display and e-Paper Applications  
*L. Guo, University of Michigan, Ann Arbor, MI, USA*
- 54.2: **Reliable and High-Performance Transparent Electrowetting Displays**  
*Ruo-Lan Chang, ITRI, Hsinchu, Taiwan, ROC*
- 54.3: **Human and Mechanical Writing Performance of eWriters**  
*Clinton Braganza, Kent Displays, Inc., Kent, OH, USA*
- 54.4L: **Late-News Paper:** Single-Mirror Interferometric Display: A New Paradigm for Reflective Display Technologies  
*John Hong, Qualcomm MEMS Technologies, Inc., San Jose, CA, USA*

### Session 55: Human Factors for 3D Displays (*3D / Applied Vision/Human Factors*)

Friday, June 6 / 9:00 - 10:20 am / Room 1

Chair: Sakuichi Ohtsuka, Kagoshima University

Co-Chair: David Hoffman, Samsung Display Co., Ltd.

- 55.1: **Distinguished Paper:** Motion Artifacts on 240-Hz OLED Stereoscopic 3D Displays  
*Paul Johnson, University of California at Berkeley, Berkeley, CA, USA*
- 55.2: **Luminance Asymmetry in Stereoscopic Content: Binocular Rivalry or Luster**  
*Marja Salmimaa, Nokia Research Center, Tampere, Finland*
- 55.3: **Enhance Users' Air-Touch Accuracy with 3D Virtual References for 3D Display User Interface**  
*Chih-Hung Ting, National Chiao Tung University, Hsinchu, Taiwan, ROC*
- 55.4: **Optimized Parallax Control of Arbitrary Viewpoint Images with Motion Parallax on Autostereoscopic Displays**  
*Takefumi Hasegawa, NLT Technologies, Ltd., Kanagawa, Japan*

### Session 56: Projection Components and System Configurations (*Projection*)

Friday, June 6 / 9:00 - 10:40 am / Room 2

Chair: Frederic Kahn, Kahn International, Inc.

Co-Chair: Ming Hsien Wu, Hamamatsu Corp.

- 56.1: **Distinguished Paper:** A Higher-Contrast Ghost-Ray-Deflecting Total-Internal-Reflection Light Separator for LED DLP Projectors  
*Jui-Wen Pan, National Chiao Tung University, Tainan, Taiwan, ROC*
- 56.2: **DPR Recycling Collar for Simpler and Brighter RGBW Pico Projectors**  
*Kenneth Li, Wavien, Inc., Valencia, CA, USA*
- 56.3: **High-Power Laser-Excited-Phosphor Suspension in Liquid for Digital Projection**  
*Kenneth Li, Wavien, Inc., Valencia, CA, USA*
- 56.4: **A Head-Up-Display Illuminator Design and Virtual-Image Estimation Method**  
*Tzu Niu, AU Optronics Corp., Hsinchu, Taiwan, ROC*
- 56.5L: **Late-News Paper:** A Real 3D Image Projected "Out-of-the-Box" Using Dual Parabolic Reflectors  
*Kenneth Li, Wavien, Inc., Valencia, CA, USA*
- 56.6L: **Late-News Paper:** Modular Multi-Projection Multi-View Autostereoscopic Display Using MEMS Laser Projectors  
*Kaan Akşit, Koç University, Istanbul, Turkey*

### Session 57: Advanced Backlighting Technology (*Display Systems*)

Friday, June 6 / 9:00 - 10:10 am / Room 5

Chair: Masaru Suzuki, SKC Haas Display Films

Co-Chair: Akihiro Tagaya, Keio University

- 57.1: **Directional BLU for Full-Resolution Field-Alternative Autostereoscopic 3D/2D and 2D/3D LCDs**  
*K. Kälantär, Global Optical Solutions, Tokyo, Japan*
- 57.2: **Enhancing LCD Optical Efficiency with a Linearly Polarized Backlight and Polarization-Preserving Light-Guide Plate**  
*Zhenyue Luo, University of Central Florida, Orlando, FL, USA*
- 57.3: **Invited Paper:** A Wide-Color-Gamut Display Using Laser Light Sources  
*Koji Minami, Mitsubishi Electric Corp., Kyoto, Japan*
- 57.4: **Late-News Paper:** Intelligible Backlight: A Controllable Illumination System for High-Efficiency and Sunlight-Readable Mobile Displays  
*Michael Robinson, RealD Inc., Boulder, CO, USA*

### Session 58: OLED TV II (*OLED TV / OLEDs / Active-Matrix Devices*)

Friday, June 6 / 10:40 am - 11:40 am / Room 6A

Chair: Hyun Jae Kim, Yonsei University

Co-Chair: Mike Hack, Universal Display Corp.

- 58.1: **A 31-in. FHD AMOLED Display Using Amorphous-IGZO TFTs and RGB Fine Metal Mesh**  
*Sai-Chang Liu, Shenzhen China Star Optoelectronics Technology Co., Ltd., Shenzhen, China*
- 58.2: **A 55-in. OLED TV Using Optimal Driving Method for Large-Sized Panel Based on InGaZnO TFTs**  
*Joong-Sun Yoon, LG Display Co., Ltd., Kyunggi-do, South Korea*
- 58.3: **Invited Paper:** Highly Reliable InGaZnO TFT Backplane for 55-in. 4K x 2K OLED Displays  
*Hiroshi Hayashi, Panasonic AVC Networks Company, Himeji, Japan*

### Session 59: e-Paper II (e-Paper and Flexible Displays)

Friday, June 6 / 10:40 am - 12:00 pm / Room 6B

Chair: Makoto Omodani, Tokai University

Co-Chair: Bo-Ru Yang, Sun Yat-Sen University

- 59.1: **Invited Paper:** Electrophoretic Display Platform Comprising BWR Particles  
Michael McCreary, E Ink Corp., Billerica, MA, USA
- 59.2: **The Contributions of Built-In Light on the Readability of e-Paper Devices**  
Tatsuya Koizuka, Nagoya University, Nagoya, Japan
- 59.3: **Invited Paper:** Developing e-Paper Standards for the Mobile Age  
John Penczek, Luminex Technologies, Boulder, CO, USA
- 59.4L: **Late-News Paper:** A First Demonstration of the Bi-Primary Color System for e-Paper with Complementary-Color Dual-Particle Electrophoretic Dispersions  
Jason Heikenfeld, University of Cincinnati, Cincinnati, OH, USA

### Session 60: 3D and Augmented-Reality Electronics (3D / Display Electronics)

Friday, June 6 / 10:40 am - 12:00 pm / Room 1

Chair: Achin Bhowmik, Intel Corp.

Co-Chair: Haruhiko Okumura, Toshiba Corp.

- 60.1: **Invited Paper:** 3D Model-Based Camera Tracking Technology for Augmented Reality  
Koji Makita, National Institute of AIST, Tsukuba, Japan
- 60.2: **Efficient Light-Field Rendering Using Depth Map**  
Young Ju Jeong, Samsung Advanced Institute of Technology, Giheung-gu, South Korea
- 60.3: **3D Glasses-Free Display with Dead-Zone Optimization for Multi-Users**  
Yi Yen, AU Optronics Corp., Hsinchu, Taiwan, ROC
- 60.4: **Overdriving LC GRIN Lens to Stabilize Lens Profile for 2D/3D Display**  
Shinichi Uehara, Toshiba Corp., Kawasaki, Japan

### Session 61: Projectors (Projection)

Friday, June 6 / 10:40 am - 12:10 pm / Room 2

Chair: Fujio Okumura, NEC Corp.

Co-Chair: Sergei Yakovenko, LensVector, Inc.

- 61.1: **Invited Paper:** How High-Frame-Rate Dual-Projector 3-D Made Its Movie Debut at the World Premiere of The Hobbit  
Terry Schmidt, Christie Digital Systems, Wellesley, Ontario, Canada
- 61.2: **Reflective Multi-View Screen and Mobile Projectors for Communication Displays**  
Munekazu Date, NTT Media Intelligence Laboratories, Nippon Telegraph and Telephone Corp., Kanagawa, Japan
- 61.3: **High-Contrast Remodulation Projector with Constant Brightness and System Adjustments**  
David Eccles, Rockwell Collins, Salt Lake City, UT, USA
- 61.4: **New 4000-lm Hybrid Solid-State Light-Source Data Projector**  
Tsuneharu Nomura, Sony Corp., Kanagawa, Japan
- 61.5L: **Late-News Paper:** Latest Developments in 3D Projection Mapping Systems  
John Vieth, Christie Digital Systems, Kitchener, Ontario, Canada

### Session 62: Novel Displays (Display Systems)

Friday, June 6 / 10:40 am - 12:00 pm / Room 5

Chair: Bill Cummings, Qualcomm MEMS Displays

Co-Chair: Jean-Pierre Guillou, Apple, Inc.

- 62.1: **Distinguished Paper:** Multi-View 3D Display System Using Arrayed Beam-Steering Devices  
Yunhee Kim, Samsung Electronics Co., Ltd., Kyunggi-do, South Korea
- 62.2: **High-Performance Transmissive Electrowetting Display Based on Bilayered Metallic Nanowire Gratings**  
Zhi-cheng Ye, Shanghai Jiao Tong University, Shanghai, China
- 62.3: **Hand-Waving Steganography by Using a High-Frame-Rate LED Panel**  
Hirotsugu Yamamoto, University of Tokushima, Tokushima, Japan
- 62.4L: **Late-News Paper:** Light-Emitting Memory: A Modular LED Panel with 10K True-Color Frame Rate for 3D Display Applications  
Bo Zhou, Altera Corp., San Jose, CA, USA

### Poster Session

Thursday, June 5 / 5:00 – 8:00 pm / Exhibit Hall A

#### Active-Matrix Devices

- P.1: **Distinguished Poster:** Fabrication of a Self-Aligned ZrInZnO TFT Using Polypropylene Carbonate Solution  
H. T. C. Tu, Japan Advanced Institute of Science and Technology, Ishikawa, Japan
- P.2: **High-Mobility Zinc Oxynitride TFT for AMOLED Displays**  
Meili Wang, BOE Technology Group Co., Ltd., Beijing, China
- P.3: **Hybrid-Type Temperature Sensor Using TFTs**  
Mutsumi Kimura, Ryukoku University, Otsu, Japan
- P.4: **Effects of Surface Polarity on Nematic Liquid Crystal Alignment**  
Young Ju Kim, Kyung Hee University, Gyeonggi-do, Korea
- P.5: **Pseudo-CMOS Circuits Using Amorphous In-Sn-Zn-O TFTs**  
Mutsumi Kimura, Ryukoku University, Otsu, Japan
- P.6: **Static Reliability of Bridged-Grain Poly-Si TFTs**  
Meng Zhang, Hong Kong University of Science and Technology, Kowloon, Hong Kong
- P.7: **High-Speed a-IGZO TFT-Based Circuits Using Back-Channel Etched Structure**  
Jin Jang, Kyung Hee University, Seoul, South Korea



- P.8: High-Resolution a-IGZO TFT-LCD Panel Fabricated with Lower Annealing Temperature**  
*Shin-Chuan Chiang, Chunghwa Picture Tubes, Ltd., Taoyuan, Taiwan, ROC*
- P.9: Study of the Origin of Major Donor States in Oxide Semiconductors**  
*Masashi Oota, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan*
- P.10: Oxide-TFT Fabrication by Using Nanorheology Printing for Display Application**  
*Hiroaki Koyama, Japan Advanced Institute of Science And Technology, Ishikawa, Japan*
- P.11: Development of Easy-Debonding IGZO TFT Array on a Flexible PI Substrate at Low Temperature**  
*Jianhua Zhang, Shanghai University, Shanghai, China*
- P.12: An a-Si:H TFT Gate Driver with Shared Dual Pull-Down Units for Large-Sized TFT-LCD Applications**  
*Shengdong Zhang, Peking University, Shenzhen, China*
- P.13: A Simple LTPS Pixel Circuit Composed of Two Transistors and One Capacitor for AMOLED Displays**  
*Chih-Lung Lin, National Cheng Kung University, Tainan, Taiwan, ROC*
- P.14: High-Mobility BCE a-Oxide TFT Fabricated Using Mixed-Acid Mo/Al/Mo Etchant**  
*Sang-Hee Park, ETRI, Daejeon, South Korea*
- P.15: High-Performance Fully Transparent Hafnium-Doped Zinc Oxide TFTs Fabricated at Low Temperature**  
*Dedong Han, Peking University, Beijing, China*
- P.16: Effect of TFT Mobility, Sub-Threshold Swing, and Threshold Voltage on AMOLED-Display Resolution**  
*Tsz Kin Ho, Hong Kong University of Science and Technology, Kowloon, Hong Kong*
- P.17: Development of Amorphous-Oxide TFTs Fabricated by a Total-Solution Process for Display Application**  
*Phan Tue, Japan Advanced Institute of Science And Technology, Ishikawa, Japan*
- P.18: A Low-Power Scan Driver Using Depletion-Mode a-IGZO TFTs for High-Resolution Displays**  
*Oh-Kyong Kwon, Hanyang University, Seoul, South Korea*
- P.19: A New Pixel Circuit to Compensate for Panel Non-Uniformity and OLED Degradation of Large IGZO AMOLED Panels**  
*Chun-Chieh Lin, AU Optronics Corp., Hsinchu, Taiwan, ROC*
- P.20: Performance Improvement of High-Mobility Amorphous Indium-Zinc-Tin-Oxide TFTs**  
*Po-Tsun Liu, National Chiao Tung University, Hsinchu, Taiwan, ROC*
- P.21: n-Type Organic TFTs with High Operational Stability**  
*Changhee Lee, Seoul National University, Seoul, South Korea*
- P.22: Top-Gate TFT with ZnO:N Channel Fabricated by Room-Temperature RF Magnetron Sputtering**  
*Meng Zhang, Hong Kong University of Science and Technology, Kowloon, Hong Kong*
- P.23: A New LCD Pixel Circuit with Low Refresh Rate Using Memory TFTs**  
*Seung-Woo Lee, Kyung Hee University, Seoul, South Korea*
- P.24: IGZO-TFT Latch Circuit with High Stability and Full-Swing Output for System-on-Panel**  
*Congwei Liao, Peking University, Shenzhen, China*
- P.25: Top-Gate Amorphous In-Ga-Zn-O TFTs Fabricated on Soda-Lime-Silica Glass Substrates**  
*Gwanghyeon Baek, University of Michigan, Ann Arbor, MI, USA*
- P.26: A Low-Power Gate Driver Using Depletion-Mode a-IGZO TFTs**  
*Chih-Lung Lin, National Cheng Kung University, Tainan, Taiwan, ROC*
- P.27: RF-Sputtered Metal-Oxide TFTs and Circuits on Aluminum Substrates with an Organic Coating**  
*Forough Mahmoudabadi, Lehigh University, Bethlehem, PA, USA*
- P.28: Study on one Infrequent Influencing Factor of TFT-LCD Lifetime**  
*Bin Feng, BOE Technology Group Co., Ltd., Beijing, China*
- P.194: Nitrous-Oxide Plasma Pre-Treatment Effect on High-Mobility ITZO TFT Bias Stress Temperature**  
*T. H. Shih, AU Optronics Corp., Hsinchu, Taiwan, ROC*

## Applications

- P.29: DNA Sensing Systems on Flexible Substrate Using Solution-Processed Oxide TFTs**  
*Hyun Jae Kim, Yonsei University, Seoul, South Korea*
- P.173L: *Late-News Poster*: A High-Quality Steerable Planar Collimator**  
*Hyungseok Bang, LG Display Co., Ltd., Kyunggi-do, South Korea*

## Applications and 3D

- P.185L: *Late-News Poster*: Polarization-Dependent Cylindrical Fresnel Lens Using the Reactive Mesogen Aligned by Nano-Groove Structure for 2D/3D Switchable Display**  
*Cheolho Lee, Kyungpook National University, Daegu, South Korea*
- P.186L: *Late-News Poster*: Novel Optical Layout of Autostereoscopic Display that Simultaneously Reproduces Two Image Elements in Each Display Pixel**  
*Vasily Ezhov, A.M. Prokhorov General Physics Institute, Moscow, Russian Federation*
- P.187L: *Late-News Poster*: Improved 3D with Super Stereoscopia Technique**  
*Kaan Akşit, Koç University, Istanbul, Turkey*
- P.188L: *Late-News Poster*: Design for a Flexible Autostereoscopic Display with Different Radius of Curvature**  
*Yun-Ting Cheng, National Taiwan University, Taipei, Taiwan, ROC*

## Applied Vision / Human Factors

- P.30: A Novel Analytical Method for Moiré Phenomenon in Autostereoscopic Displays**  
*Ren-wei Liao, AU Optronics Corp., Hsinchu, Taiwan, ROC*
- P.31: Investigation of the Actual Viewing Conditions in the Chinese Home**  
*Xuefei Zhong, Southeast University, Nanjing, China*
- P.32: Mura-Grade Evaluation Based on S-CIELAB Color System**  
*Toshio Asano, Hiroshima Institute of Technology, Hiroshima, Japan*
- P.33: Which Color-Gamut Metric Best Predicts Human Display Preference?**  
*James Hillis, 3M Co., Maplewood, MN, USA*
- P.34: Evaluation of Readability for Tablet Devices by the Severity of Cataract Cloudiness**  
*Yuki Ishii, Nagoya University, Nagoya, Japan*
- P.35: How to Obtain Optimum Overdrive Values of LCDs Only by the Human Eye**  
*Seung-Woo Lee, Kyung Hee University, Seoul, South Korea*
- P.36: The Effects of 4K High-Resolution Displays on the Sway of the Human Body: A Comparison of 2D and 3D Images**  
*Kazuki Yoshikawa, Nagoya University, Aichi, Japan*

- P.37: Readability of Displays in Bright Outdoor Surroundings**  
*Kjell Brunnström, Acreo Swedish ICT AB, Kista, Sweden*
- P.38: Paired Comparison to Assess Dependency of Visibility on Panel Boundary Division in Weather Forecast Maps**  
*Sakuichi Ohtsuka, Kagoshima University, Kagoshima, Japan*
- P.39: A Novel Color-Gamut Quantization Method for Wide-Color-Gamut Displays**  
*Kuei-Yin Lin, AU Optronics Corp., Hsinchu, Taiwan, ROC*
- P.40: Eye Movement While Reading e-Books**  
*Hideaki Takahira, Tokai University, Tokyo, Japan*
- P.174L:Late-News Poster: Analysis of the Fundamental Characteristics of the Movement of Gaze and Hand When Holding an e-Book in the Hand**  
*Kei Kikuchi, Tokai University, Tokyo, Japan*
- P.189L:Late-News Poster: Determination of Depth Enhancement through Assessments of Perceived Blur in 3D Displays**  
*Chao-Hua Wen, National Taiwan University of Science and Technology, Taipei, Taiwan, ROC*
- P.193L:Late-News Poster: Optimal Tone Curve Characteristics of Transparent Display for Preferred Image Reproduction**  
*Youngshin Kwak, UNIST, Ulsan, South Korea*

## Display Electronics

- P.41: Active-Matrix Display with In-Pixel D/A Conversion Driven by Digital Pulse Width Modulation**  
*Ya-Hsiang Tai, National Chiao Tung University, Hsinchu, Taiwan, ROC*
- P.42: A New Driving Method for PS-BP LCD**  
*Xinhui Zhong, Shenzhen China Star Optoelectronics Technology Co., Ltd., Shenzhen, China*
- P.43: A Novel TFT Pixel Design for Active-Matrix FLC with Gray-Scale Generation**  
*Tsz Kin Ho, Hong Kong University of Science and Technology, Kowloon, Hong Kong*
- P.44: Master-Slave Pixel Concept Used for Improved Sensor Display Array Circuits**  
*Nikolas Papadopoulos, University of Waterloo, Waterloo, Ontario, Canada*
- P.45: A Feedback Method for Assuring Reliable Visual Quality of Locally Dimmed LCDs**  
*Daniel Schäfer, Saarland University, Saarbruecken, Germany*
- P.46: A Real-Time Computer-Generated Integral-Imaging System Based on Multiple Orthographic Frustum Combining**  
*Qiong-Hua Wang, Sichuan University, Chengdu, China*
- P.47: New Signal-Processing Method to Improve Image Quality of RGBW Display**  
*Masaaki Kabe, Japan Display, Inc., Kanagawa, Japan*
- P.48: Development of a Novel RGBW Mobile Display with a Local-Dimming Backlight System**  
*Tsutomu Harada, Japan Display, Inc., Kanagawa, Japan*
- P.49: New Blue-Phase LCD Driving Pixel Circuit for a-IGZO TFT with Large Operational Voltage**  
*Chih-Lung Lin, National Cheng Kung University, Tainan, Taiwan, ROC*
- P.50: Driving System for RGBW AMOLED Display**  
*Szu-Heng Tseng, BOE Technology Group Co., Ltd., Beijing, China*
- P.51: a-IGZO TFT Based Operational Amplifier and Comparator Circuits for the Adaptive DC-DC Converter**  
*Hojin Lee, Soongsil University, Seoul, South Korea*
- P.52: A New Dynamic Headroom Controller Using Storage Delay Time of BJT for Low-Power-Consumption LED Backlight**  
*Jin Huh, KAIST, Daejeon, South Korea*
- P.53: Real-Time Super-Resolution for 4K x 2K TVs Using Edge-Directed Unsharp Masking Sharpening Method**  
*Fang-Cheng Lin, National Chiao Tung University, Hsinchu, Taiwan, ROC*
- P.54: Image Segmentation Using Densely Constructed Mean Shift Vectors**  
*HanJoo Cho, Pohang University of Science and Technology, Pohang, South Korea*
- P.55: Adaptive Noise-Reduction Method Using Variable Window Size Based on Region Analysis**  
*Jae Hwan Lim, Pohang University of Science and Technology, Pohang, South Korea*
- P.56: A Single-Inductor Bipolar-Output DC/DC Converter with High Efficiency Over Wide Load Range for Active Matrix OLED**  
*Ke-Horng Chen, NCTU, Hsinchu, Taiwan, ROC*
- P.57: Pixel Design of 5-in. Full-HD IPS-LCD Using Wall Electrodes**  
*Takato Hiratsuka, Japan Display, Inc., Chiba, Japan*
- P.175L:Late-News Poster: A 2.0-Gbps Intra-Panel Interface with Automatic Calibration for Chip-on-Glass Super-High-Definition TFT-LCD Applications**  
*Yohei Ishizone, CerebrEX, Inc., Osaka, Japan*
- P.176L:Late-News Poster: A 3.7-Gb/sec Clock-Embedded Intra-Panel Interface for Large-Sized UHD 120-Hz LCD-TV Application**  
*Hyun-Kyn Jeon, Silicon Works Co., Ltd., Daejeon, South Korea*
- P.190L:Late-News Poster: Low-Frequency-Driving Display to Reduce Logic Power in LCDs**  
*Oh Dae Seok, LG Display Co., Ltd., Kyunggi-do, South Korea*

## Display Manufacturing

- P.58: Frame-Type Backcover Design of Large-Sized LCD Modules**  
*Chengling Lv, Shenzhen China Star Optoelectronics Technology Co., Ltd., Shenzhen, China*
- P.59: Electrically High Stable, Flexible, Transparent, and Conductive Hybrid Electrodes Using an Indium-Doped Zinc Oxide Buffer Layer on Silver Nanowires**  
*Byeong Kwon Ju, Korea University, Seoul, South Korea*
- P.60: Basic Design for Halftone Performance of Organic-Insulation Negative PAC for a Novel IPS Structure**  
*Chul Ho Park, LG Display Co., Ltd., Kyunggi-do, South Korea*
- P.61: WITHDRAWN**
- P.62: Brightness and Contrast Improvement of a Display Panel by Using Anti-Reflection Films Nanoimprinted by Density-Graded Nanoporous Silicon**  
*Pei-Kuen Wei, Academia Sinica, Taipei, Taiwan, ROC*
- P.63: Highly Transparent and Rub-Resistive Nanostructured Diamond-Like Carbon Protective Coatings for Display Applications**  
*Da-Hua Wei, National Taipei University of Technology, Taipei, Taiwan, ROC*
- P.64: Eliminating Buckling in Vertical Four-Point Bend Testing**  
*K. Hemanth Vepakomma, Corning Inc., Corning, NY, USA*
- P.65: Study on Resin as the Passivation Layer of Retina Displays for Mobile-Phone Screens**  
*Changjiang Yan, BOE Optoelectronics Technology Co., Ltd., Beijing, China*
- P.66: The Mechanical Properties of Aluminosilicate Glass with Chemical Strengthening**

*Kuo Chou Chang, G-Tech Optoelectronics Corp., Miaoi, Taiwan, ROC*

- P.67: Research on Thermal Mura in Edge-Type LCD Module and Improvement by Heat-Sink Design**  
*Chengling Lv, Shenzhen China Star Optoelectronics Technology Co., Ltd., Shenzhen, China*
- P.68: Analysis of Movable Mura and Improvement in LCD Cells**  
*Chengling Lv, Shenzhen China Star Optoelectronics Technology Co., Ltd., Shenzhen, China*
- P.69: A Study of Image Sticking for Automotive Displays**  
*Chang-Hoon Kim, LG Display Co., Ltd., Kyunggi-do, South Korea*
- P.177L: *Late-News Poster*: Development of High-Strength Chemically Strengthened Glass**  
*Kosuke Kawamoto, Nippon Electric Glass co., Ltd., Shiga, Japan*
- P.192: Evaluation of Dimensional Stability During Low-Temperature Poly-Si TFT Fabrication Process Using an Ultra-Low Thermal-Shrinkage Glass Substrate**  
*Kazutaka Hayashi, Asahi Glass Co., Ltd., Kanagawa, Japan*

## Display Measurement

- P.70: Multilayered Silicon and Silicon Oxide Subwavelength Grating as a Reflective Polarizer in the Visible Region**  
*Su Pan, Hong Kong University of Science and Technology, Kowloon, Hong Kong*
- P.71: Simulation and Experimental Study on Light Leakage Caused by Glass Retardation in ADS Modes**  
*Yafeng Yang, BOE Technology Group Co., Ltd., Beijing, China*
- P.72: Novel Color-Gamut Area Specification**  
*Wei-Wei Zheng, TCL Corporate Research, Shenzhen, China*
- P.73: Brightness Inversion of the Polymer-Sustained-Alignment (PSA) Mode of Curved Displays**  
*Shang-wei Hsieh, AU Optronics Corp., Hsinchu, Taiwan, ROC*

## Display Systems

- P.74: Adaptable Light Beaming and Shaping with Lens Array**  
*Yuning Zhang, Southeast University, Nanjing, China*
- P.75: Viewing-Zone Expansion for Autostereoscopic Display with Directional Backlight Using Linear Fresnel-Lens Array**  
*Takuya Mukai, University of Tsukuba, Tsukuba, Japan*
- P.76: *Distinguished Student Poster*: Viewing-Angle-Switchable Display with a Compact and Directional Backlight Module**  
*Yi-Jun Wang, Shanghai Jiao Tong University, Shanghai, China*
- P.77: Roll-to-Roll Manufacturing of RGB Phosphor Sheets for Solid-State Lighting and Large-Area Flexible Displays**  
*Hisham Menkara, PhosphorTech, Kennesaw, GA, USA*
- P.78: An Interactive 360° Floating 3D Display Based on Gesture Recognition**  
*Li Feng, Zhejiang University, Hangzhou, China*
- P.79: An Autostereoscopic Display Structure Based on Diffractive Optical Elements and Tunable Refractive Elements**  
*Chiao-Wei Hsu, National Taiwan University, Taipei, Taiwan, ROC*
- P.80: Intelligent Remote Light-Emitting Systems Using PMMA and CuInS<sub>2</sub> Nanocrystals Composite Films**  
*Haizheng Zhong, Beijing Key Laboratory of Nanophotonics and Ultrafine Optoelectronic Systems, Beijing, China*
- P.81: Local Dimming Using a Grid-Shaped Reflector in Large-Sized LED-Backlit LCD TVs**  
*Zong Qin, National Chiao-Tung University, Hsinchu, Taiwan, ROC*
- P.82: Holographic Display System Based on Complex Amplitude Modulation**  
*Nannan Zhang, Beijing Institute of Technology, Beijing, China*
- P.83: Large-Depth Integral Imaging Using Plano-Convex Micro-Lens Array and Flat-Panel Array**  
*Qiong-Hua Wang, Sichuan University, Chengdu, China*
- P.191L: *Late-News Poster*: Analysis of Backlight Structure Based on Different LCD Eigenmode**  
*Jin-ku Lv, BOE Display Technology Co., Ltd., Beijing, China*

## Emissive Displays

- P.84: Towards a Complete Understanding of the Electronic Characteristics of Powder ACCEL Lamps**  
*Chris Winscom, Brunel University, Uxbridge, UK*
- P.85: ZnO Thin-Film Phosphor Prepared on Different Substrates by Novel Multiple Reducing Annealing**  
*Chaoyang Li, Kochi University of Technology, Kami, Japan*
- P.86: Improved Performance of Quantum-Dot LEDs by Using a Charge-Blocking Layer**  
*Changhee Lee, Seoul National University, Seoul, South Korea*
- P.87: All-Solution Process for Color-Tunable Quantum-Dot LEDs**  
*Jing Chen, Southeast University, Nanjing, China*
- P.88: All-Inorganic Quantum-Dot Light-Emitting Devices Prepared by Solution-Process Route**  
*Jing Chen, Southeast University, Nanjing, China*
- P.89: Development of 51-in. PDPs**  
*Qun Yan, Sichuan COC Display Device Co., Ltd., Mianyang, China*
- P.178L: *Late-News Poster*: Blue-Green BaSi<sub>2</sub>O<sub>2</sub>N<sub>2</sub>:Eu<sup>2+</sup> Phosphor for LEDs**  
*Jongsu Kim, Pukyong National University, Busan, South Korea*
- P.179L: *Late-News Poster*: Chemical-Stability Enhancement of K<sub>2</sub>SiF<sub>6</sub>:Mn<sup>4+</sup> by Metal (Oxide) Coating**  
*Jongsu Kim, Pukyong National University, Busan, South Korea*

## e-Paper and Flexible Displays

- P.90: Advancing Behavior of Fluids over Patterned Hydrophobic Surface for Electrowetting Displays**  
*Jun Xia, Southeast University, Nanjing, China*
- P.91: What Is the Ideal ITO Composition for Touch-Sensor Deposition on a Flexible Substrate Made with Rotary Cathodes?**  
*Paul Lippens, UMICORE Thin Film Products, Balzers, Liechtenstein*
- P.92: Encapsulation Adhesive Possessing High Water Barrier and Low Corrosive Properties for a Flexible Electronic Device**  
*Satoshi Naganawa, Lintec Corp., Saitama, Japan*
- P.93: Highly Conductive and Uniform Graphene Hybrid Electrode through Chemical Reduction for Flexible OLEDs**  
*Gufeng He, Jiao Tong University, Shanghai, China*
- P.94: Ultra-Thin Graphene Oxide/Polymer Multi-Layer Encapsulation for Flexible OLED Displays**  
*Hwa-Yong Lee, Hong-ik University, Seoul, South Korea*
- P.95: Newly Discovered Property of Electric and Magnetic Dual-Driven Twisting Ball Display**  
*Yusuke Komazaki, The University of Tokyo, Tokyo, Japan*

- P.96: A Debonding Technique with Inorganic Buffer Layer on Flexible Display Panel**  
*Chien-Ying Chen, AU Optronics Corp., Hsinchu, Taiwan, ROC*

## Liquid-Crystal Technology

### 3D

- P.97: A Novel Fresnel-Type Liquid-Crystal Lens for Autostereoscopic 3D Display**  
*I-Wei Chen, AU Optronics Corp., Hsinchu, Taiwan, ROC*
- P.98: Autostereoscopic 2D/3D Switchable Display Using Liquid-Crystal Lenticular Lens**  
*Qiao-Sheng Liao, Shenzhen China Star Optoelectronics Co., Ltd., Shenzhen, China*
- P.99: 2D/3D Switchable, 3D Rotatable, and 2D/3D Coexistent Autostereoscopic Display Using Multi-Functional Liquid-Crystal Lens Array**  
*Tai-Hsiang Jen, National Chiao Tung University, Hsinchu, Taiwan, ROC*
- P.100: A 2D/3D Switchable Display with Dramatically Reduced Crosstalk**  
*Ruidong Zhu, University of Central Florida, Orlando, FL, USA*
- P.101: Liquid-Crystal Fresnel Zone Lens Based on Single-Sided Patterned Photoalignment Layer**  
*Xiaoqian Wang, Hong Kong University of Science and Technology, Kowloon, China*
- P.102: Research on Adaptive Modal LC Lens with Central Electrode Structure and ITO High-Resistance Layer**  
*Qing Li, Southeast University, Nanjing, China*

### Alignment

- P.103: Nanomesh Aluminum Films for LC Alignment: Theoretical and Experimental Modeling**  
*Victor Belyaev, Moscow Region State University, Moscow, Russian Federation*
- P.104: Bistable Nano-Structured Alignment Surface by Nanoimprint Lithography**  
*Chung Yung Lee, Hong Kong University of Science and Technology, Kowloon, Hong Kong*
- P.105: Modelling of Liquid Crystals at the Pixel Edge**  
*Zijun Nie, University College London, London, UK*
- P.106: Pretilt Angles and Liquid-Crystal Director-Deformation Profiles of Inverse TN-LC Cells**  
*Sheng-Ya Wang, National Chiao Tung University, Tainan, Taiwan, ROC*

### Blue Phase

- P.107: Spatial-Multiplexed Dual-View Display Using Blue-Phase Liquid Crystal**  
*Qiong-Hua Wang, Sichuan University, Chengdu, China*
- P.108: WITHDRAWN**
- P.109: Distinguished Student Poster: Diluter Effects on High-Dielectric-Anisotropy Blue-Phase Liquid Crystals**  
*Yuan Chen, University of Central Florida, Orlando, FL, USA*
- P.110: Stabilizing Blue-Phase Liquid Crystal by Stabilization of Double-Twist Cylinders with Photo-Reactive Chiral Mesogen**  
*Seung Hee Lee, Chonbuk National University, Jeonju, South Korea*
- P.111: Polymer Effect on Polymer-Stabilized Blue-Phase Liquid Crystals**  
*Emine Kemiklioglu, Liquid Crystal Institute, Kent State University, Kent, OH, USA*

### FFS/IPS

- P.112: Electrode Surface Modified VA-IPS Liquid-Crystal Device**  
*Jian-Siang Huang, National Chiao Tung University, Hsinchu, Taiwan, ROC*
- P.113: Photoalignment Technology for High-Performance IPS-LCDs: IPS-NEO Technology**  
*Noboru Kunimatsu, Japan Display, Inc., Mobara, Japan*
- P.114: A Liquid-Crystal Mode with Combined Fringe and In-Plane-Switching Fields by Using a Bottom Floating Electrode**  
*Hak-Rin Kim, Kyungpook National University, Daegu, South Korea*
- P.115: A Super Fringe-Field-Switching Pixel Structure with Low Driving Voltage**  
*Sikun Hao, Shenzhen China Star Optoelectronics Technology Co., Ltd., Shenzhen, China*
- P.116: Novel Approach to Achieve Conventional Polyimide-Less IPS/FFS LCDs**  
*Seung Hee Lee, Chonbuk National University, Jeonju-si, South Korea*
- P.117: Investigation on the Movement of Ions in the Fringe-Field-Switching Mode Depending on the Resistivity of the Alignment Layer and Dielectric Anisotropic Sign of Liquid Crystal**  
*Seung Hee Lee, Chonbuk National University, Jeonju-si, South Korea*

### Films and Backlight

- P.118: Ellipsoidal Light-Diffusing Film with a Narrow-Louver Micro-Structure of Refractive Index**  
*Baku Katagiri, LINTEC Corp., Saitama, Japan*
- P.119: High-Efficiency LCDs Using Quantum-Dot Films**  
*Jeff Yurek, Nanosys, Milpitas, CA, USA*
- P.180L: Late-News Poster: Achromatic Polarizer Using Novel Dichromatic Dye for Low-Power Display Applications**  
*Takahiro Ishinabe, Tohoku University, Sendai, Japan*

### Other LCD Modes

- P.120: Nucleation-Controlled Bistable Twisted-Nematic Display**  
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